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	Application No.	Applicant(s)	
Notice of Allowability	09/276,273	LOWREY ET AL.	
House of Anomability	Examiner	Art Unit	
	Phat X. Cao	2814	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. X This communication is responsive to 4/29/05.			
2. The allowed claim(s) is/are <u>258,259,261-268 and 276-298</u> .			
3. The drawings filed on are accepted by the Examiner.			
4.			
Attachment(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☑ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	5. ☐ Notice of Informal P 6. ☐ Interview Summary Paper No./Mail Dat 7. ☒ Examiner's Amendr 8. ☒ Examiner's Stateme 9. ☐ Other	(PTO-413), te ment/Comment	

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EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

IN THE CLAIM: (typographical error)

Claim 293, line 1, change "294" to -- 291 --

2. The following is an examiner's statement of reasons for allowance:

The prior art of record fails to disclose all the limitations recited in the base claims, including the combination of a memory element structure comprising: a conductive material lining the sidewall surface of the opening, the conductive material formed over a portion of the bottom surface of the opening, the portion being less than the entire bottom surface; a second dielectric material formed over the conductive material within the opening; and a programmable resistance material coupled to a top surface of the conductive material (claim 278), the top surface having a lateral dimension less than 1000 angstroms (claims 258, 291, 295).

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phat X. Cao whose telephone number is (571) 272-1703. The examiner can normally be reached on Monday - Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

PC June 30, 2005

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